

Derwent Innovations Index® Help

About Derwent Innovations Index

Derwent Innovations Index is a research tool that provides Web access to more than 14,800,000 patents with links to cited and citing patents, cited articles, and full-text patent data sources.

Derwent Innovations Index opens the power of patent searching to all levels of an organization, allowing you to browse patent records by entering simple search queries. Coverage includes patent records from Derwent World Patents Index and patent citation information from Derwent Patents Citation Index.

Derwent Innovations Index also includes *Derwent Chemistry Resource* (separate subscription required), a unique database containing chemical structures that you can search by entering chemical search terms and/or chemical structures.

Derwent Chemistry Resource allows you to browse through the chemical structure database to develop new ideas on compound structure advances and to learn of new compounds that have hit the market.

Information About ...

- [Derwent Indexes](#)
- [Derwent Class Codes](#)

Requirements

Derwent Chemistry Resource - a subscription is required to search for compound structures.

MDL® Chime plug-in - Chemistry users must first download and install MDL Chime before they can search for and view chemical structures. Chime is a chemical structure visualization plug-in created by MDL that works with your browser, allowing you to draw and manipulate chemical structures.

Information About ... [MDL Chime Download Instructions](#)

About this Product

You can use *Derwent Innovations Index* to:

- Determine the extent to which an invention has been protected internationally;
- Search for English language equivalents in order to review patent documents published in an unfamiliar language;
- Research technological advances within your field;
- Find potential gaps in the marketplace;
- Review the novelty of your company's invention;
- Track technological trends within your field;
- Keep abreast of licensing opportunities; and
- Avoid/watch for patent infringement.